

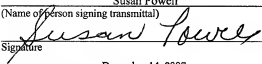
IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant(s) : Koichiro KISHIMA et al.
Serial No. : 10/540,720
Filed : January 13, 2006
For : METHOD FOR MANUFACTURING SEMICONDUCTOR
SUBSTRATE AND SEMICONDUCTOR SUBSTRATE
Art Unit : 2818
Confirmation No. : 2419
Examiner : David Nhu

745 Fifth Avenue
New York, New York 10151

CERTIFICATE OF ELECTRONIC FILING

I hereby certify that this correspondence is being transmitted via
Electronic Filing Services on December 14, 2007.

Susan Powell
(Name of person signing transmittal)

Signature
December 14, 2007
Date of Signature

AMENDMENT UNDER 37 CFR 1.111

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

In response to the non-final Office Action mailed October 11, 2007, having a
shortened term of reply ending on January 11, 2008, please amend the above-identified
application as follows: